# ELECTRO ANNEALING-INDUCED MODIFICATIONS IN Nb SQUIDs



S.Collienne<sup>1</sup>, R.B.G. Kramer<sup>2</sup>, J. Van de Vondel<sup>3</sup>, B. Raes<sup>3</sup>, and A.V. Silhanek<sup>1</sup>

<sup>1</sup> Experimental Physics of Nanostructured Material, Q-MAT, CESAM, Université de Liège, B-4000 Sart Tilman, Belgium.
<sup>2</sup> Institut Néel, CNRS, Université Grenoble Alpes, Grenoble, France.

<sup>3</sup> Laboratory of Solid-State Physics and Magnetism, KU Leuven, B-3001 Leuven, Belgium.

## im.

### **SQUID : Superconducting QUantum Interference Device**





#### What is electromigration/electro-annealing?







.**IÈGE** niversité



- SQUID is composed of two Josephson junctions in parallel forming a loop.
- Josephson junction (JJ) is formed by a weak link between two superconducting materials.
- Examples of weak link: an insulator, a metal, a superconductor of smaller T<sub>C</sub>, a **Dayem bridge**.
- The weak link determines the properties of the JJ, and consequently, of the SQUID.
- SQUIDs are among the most sensitive magnetic field sensors.
- Investigate the possibilities of EM/EA to go below the limit of conventional lithography (few tens of nm).
- Determine how EM/EA is able to tune the characteristics of a SQUIDs (oscillations, critical current, etc).

## **SEM imaging**

- Ambient temperature,  $P \sim 10^{-6}$  mbar.
- Current crowding induces modification of the two junctions.

 $\Phi_0$  = flux quantum = h/2e = 2.068.10<sup>-15</sup> Tm<sup>2</sup>

 $\bigcirc$ 

Ally

CONTEXT

O CONCLUSION O

EMO

 Imaging methods confirm that the effect of EM/EA are located at the junctions of the SQUIDs.

#### Virgin state : layout and V(I)













#### **AFM imaging**

Ambient temperature and pressure.
EM create important atomic movements, creating hillocks

• EM/EA process allows access to large interval for charateristic parameters of the SQUIDs

 $\bigcirc$ 

- *I* [μA] *I* [μA]
- Size of the Dayem bridge and etching process tremendously influence the critical current value.
- Bigger junction size allows larger critical current but irreversible V(I).
- Larger Dayem bridge favours the formation of a hot spot.

## **Progressive electro-annealing**



- The first 5 EA processes show improvement of the superconducting properties (lower normal resistance  $R_N$  and higher  $T_C$ ).
- EA processes from 6 to 11, show a deterioration of the critical temperature and normal resistance.
- EA 12 and 13 show an unexpected and nearly total recovery of the original superconducting state (data to be confirmed).

#### at the junctions locations.



#### **Critical current and SQUIDs oscillations**





#### REFERENCES

[1] Zharinov et al. Rev. Sci. Instrum. 89, 043904 (2018)
 [2] Lombardo et al. Nanoscale, 10, 1987 (2018)
 [3] Keijers et al. Nanoscale, 10, 1039 (2018)

#### CONTACT

Simon Collienne scollienne@uliege.be www.mate.ulg.ac.be

